

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2372	substrate and gate and silicide and refractory and ((field oxide) or fox)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/08/04 09:51
L2	2044	1 and source and contact	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/08/04 09:52
L3	380	2 and polysilicon and protective	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/08/04 09:53
L4	24	("5304502").URPN.	USPAT	ADJ	ON	2005/08/04 10:26